

Notice of References Cited

Application/Control No.

09/745,350

Applicant(s)/Patent Under
Reexamination
SABNIS ET AL.

Examiner

Nicole M. Barreca

Art Unit

1756

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U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
	A	US-			
	B	US-			
	C	US-			
	D	US-			
	E	US-			
	F	US-			
	G	US-			
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	I	US-			
	J	US-			
	K	US-			
	L	US-			
	M	US-			

FOREIGN PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N	JP 8-064492	03-1996	JP	Yoichi	H01L 21/027
	O					
	P					
	Q					
	R					
	S					
	T					

NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	Linliu et al., "A Novel Polymeric Anti-Reflective Coating (PARC) for DRAM, Flash and Logic Device with 0.1 micron COSi2 Gate", Worldwide Semiconductor Manufacturing Corp., 2000
	V	
	W	
	X	

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